

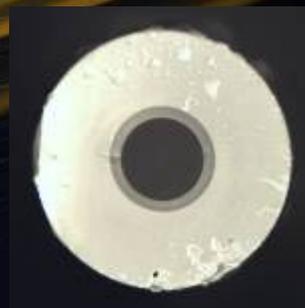
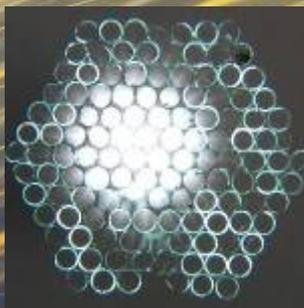


Optická vlákna

Laboratoř optických vláken

Ústav fotoniky a elektroniky, AVČR, v.v.i.

www.ufe.cz/dpt240; www.ufe.cz/~kasik



Ústav fotoniky a elektroniky AV ČR, v.v.i.



*Prof. Jiří Homola
Česká hlava 2009*



ZÁKLADNÍ VÝZKUM:

fotonika

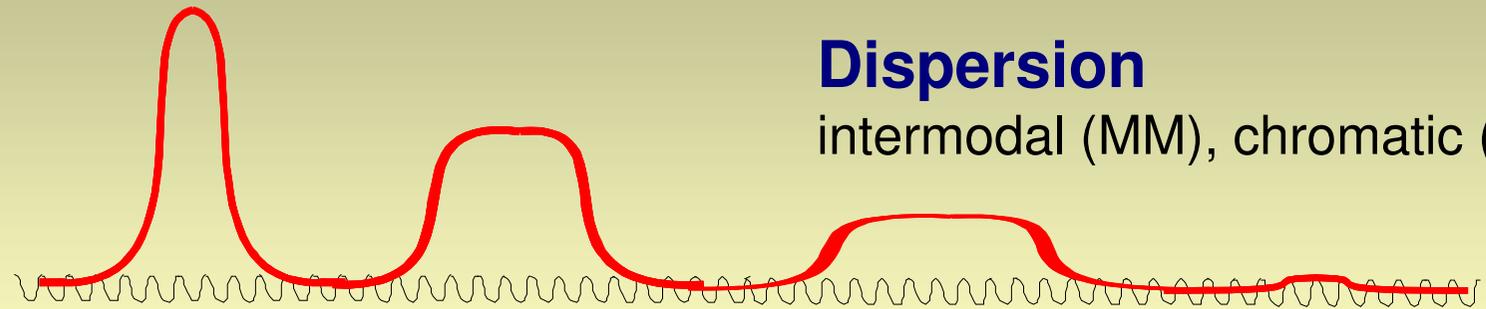
- **optická vlákna**
- **vláknové lasery a zesilovače**
- **optické biosenzory**

státní etalon času, detekce pole živých buněk

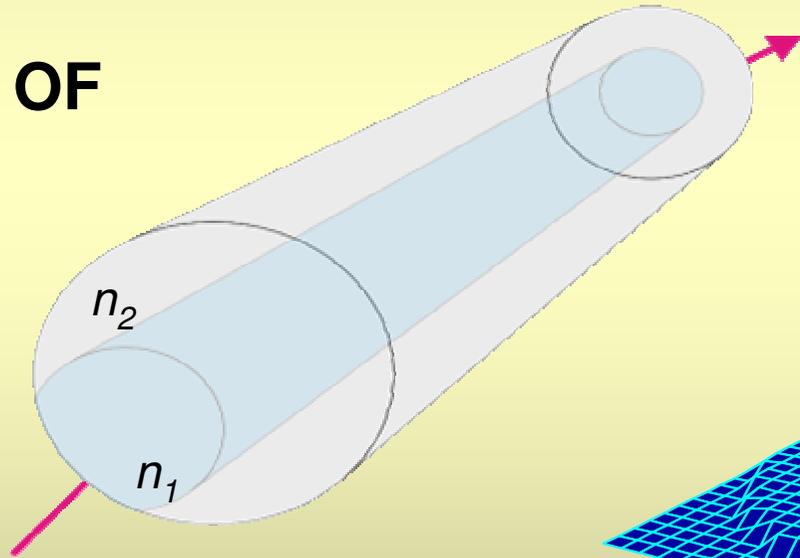
Outline

1. **Intro**
2. **Technology**
3. **Application**
 - **Telecommunications**
 - **Fiber lasers, amplifiers**
 - **Fiber sensors**
4. **Optical fibres – materials and structures**
5. **Summary**

Fibers, properties – dispersion, structure

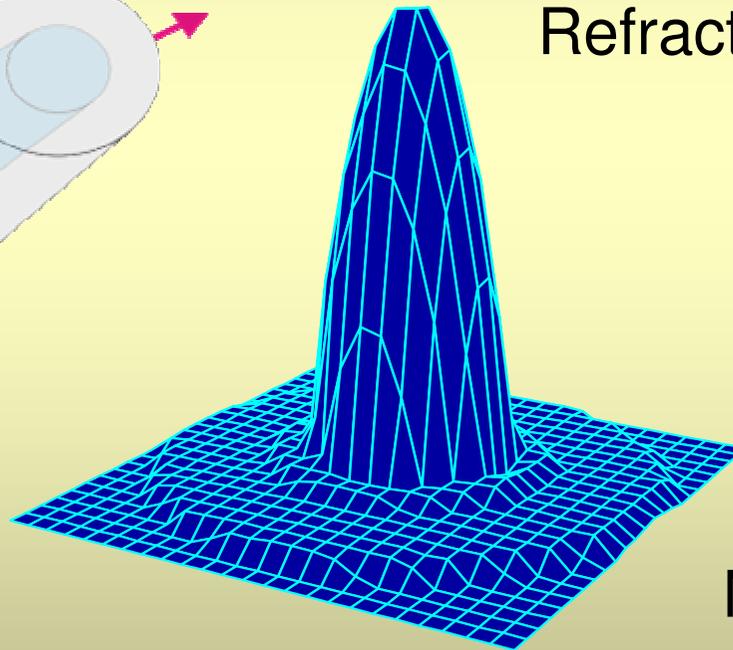


OF



$$n_1 > n_2$$

Refractive-index profile



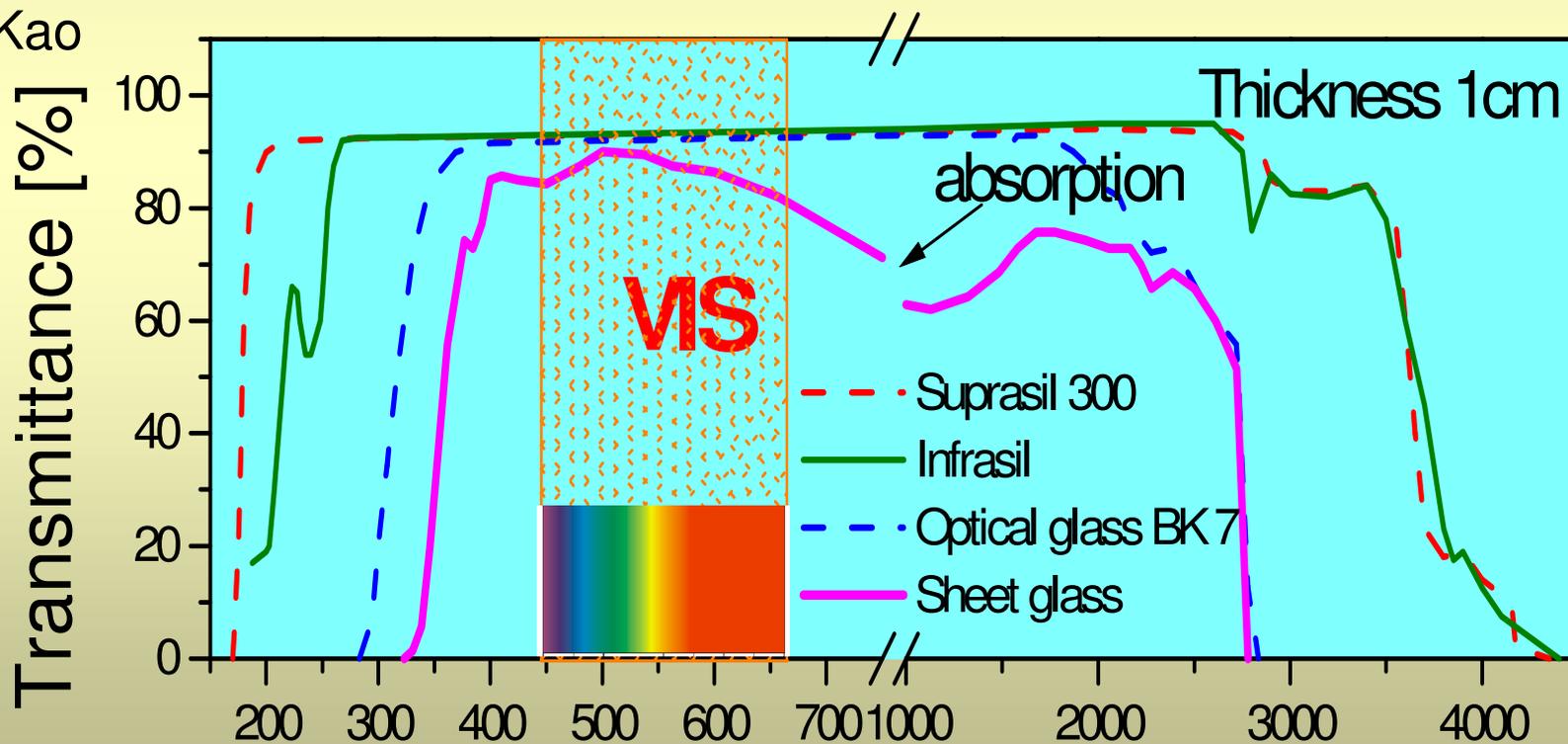
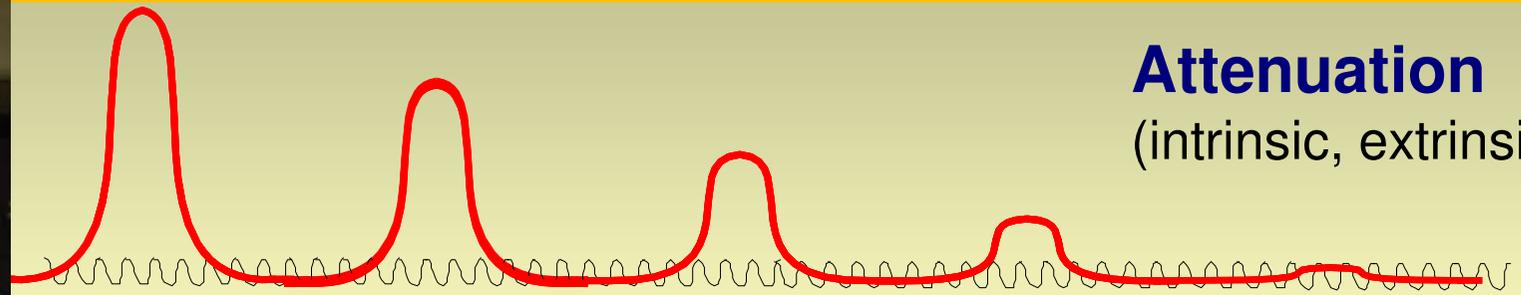
NA_{SM} (0.1-0.25)

NA_{MM} (0.2-0.5)

Optical properties and material purity



Ch. Kao



Material purity



1. Per Analysis – PA (99 - 99,5 %)
2. Semiconductor – PP (99,9995 %)
3. Ultra-pure - FO Optipur / for trace analysis [ppb]

% – 10^{-2}

ppm – 10^{-6} (parts per million)

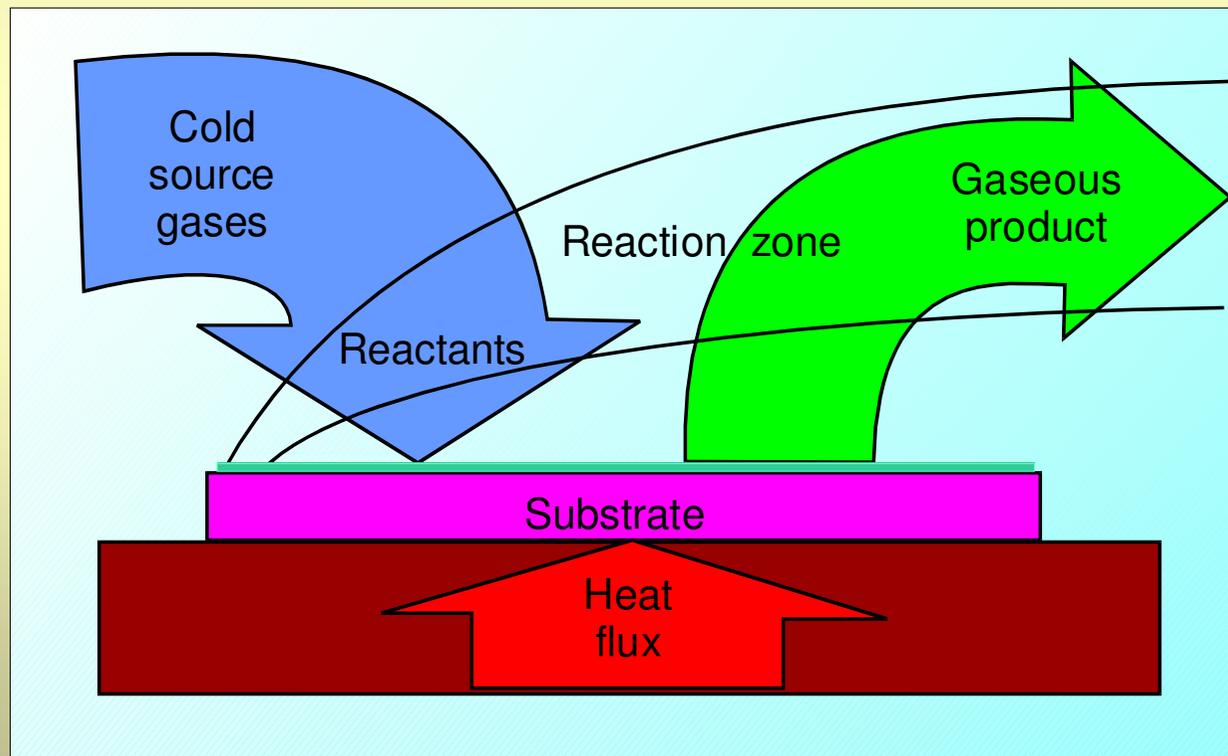
ppb – 10^{-9} (parts per billion) : **content of impurities acceptable in FO Optipur materials**

Ultra-pure technologies - CVD !

TECHNOLOGY

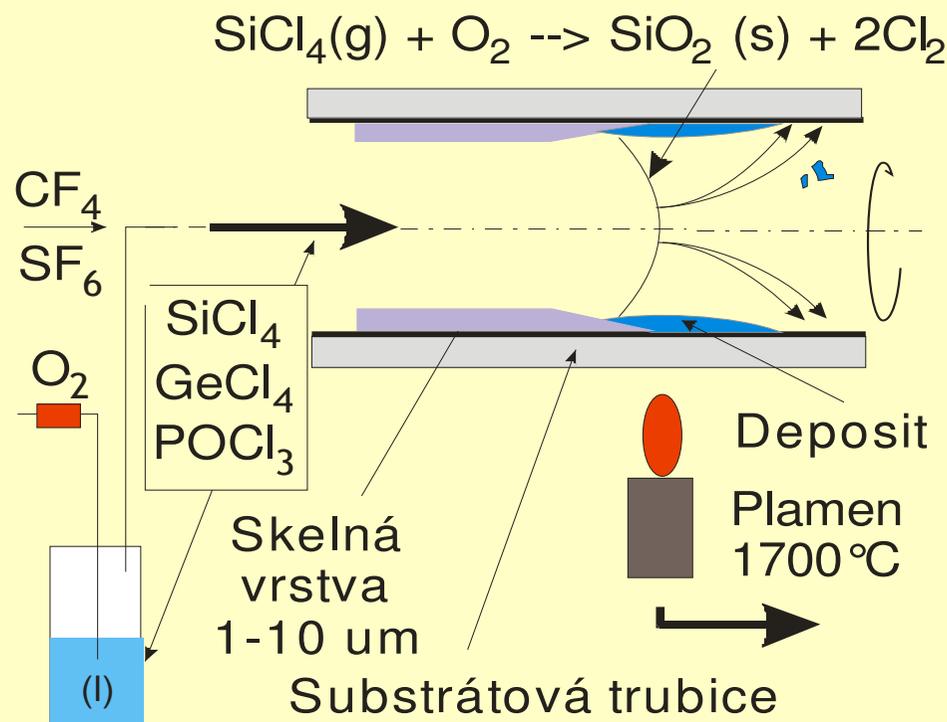
CVD - Chemical Vapor Deposition

= production and deposition of material in solid state from starting materials in gaseous state through a chemical reaction :

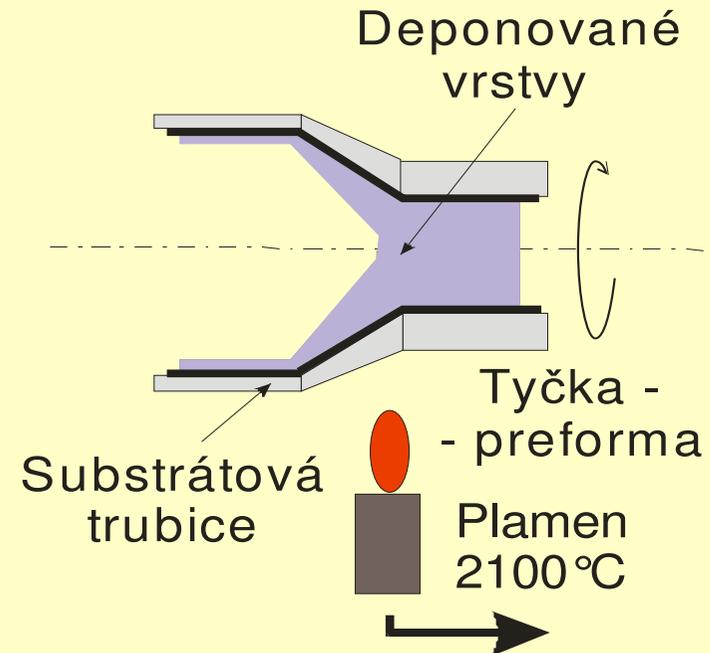


MCVD – Chemical Vapor Deposition

1. Depozice



2. Kolaps

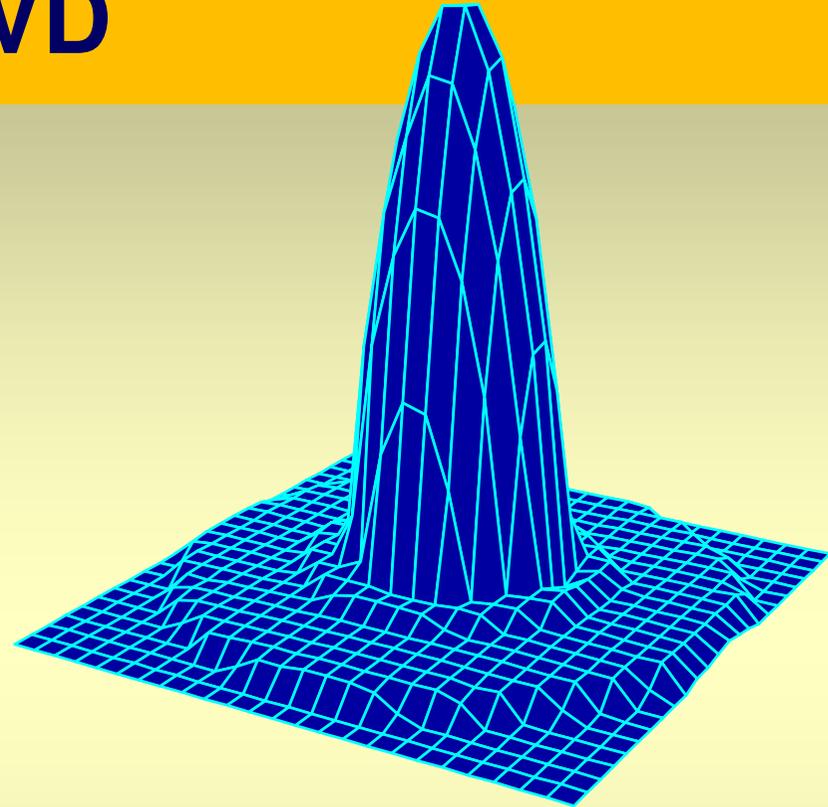


- Sequential sintering of **thin glassy layers** (of thickness 1-20 μm) onto inner wall of silica substrate **resulting in bulk material – preform**
- **high purity** (~ 10¹ ppb) **high preciseness** (better than 1 %)

MCVD



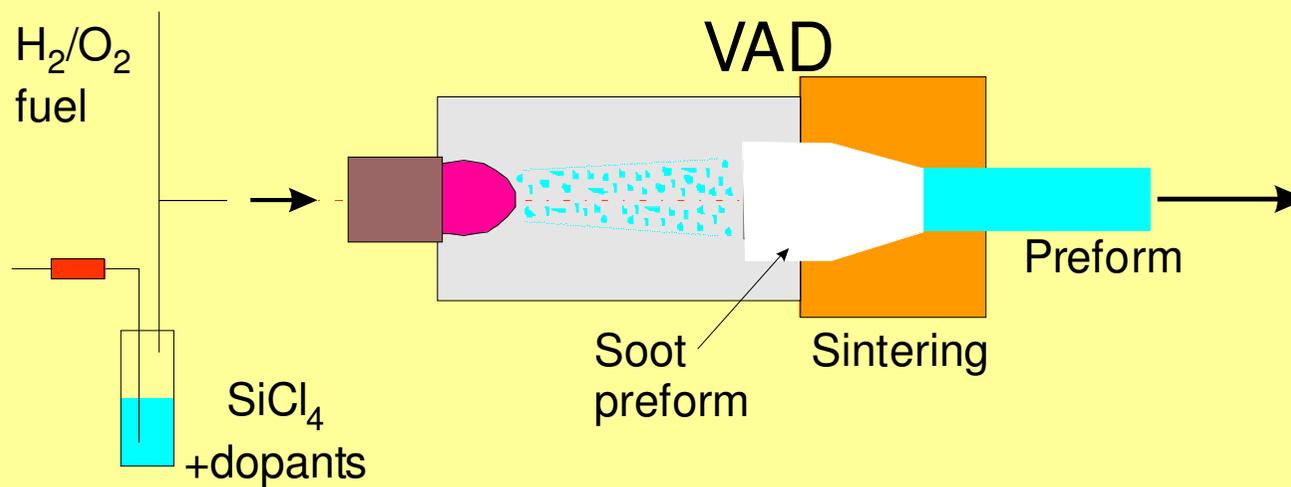
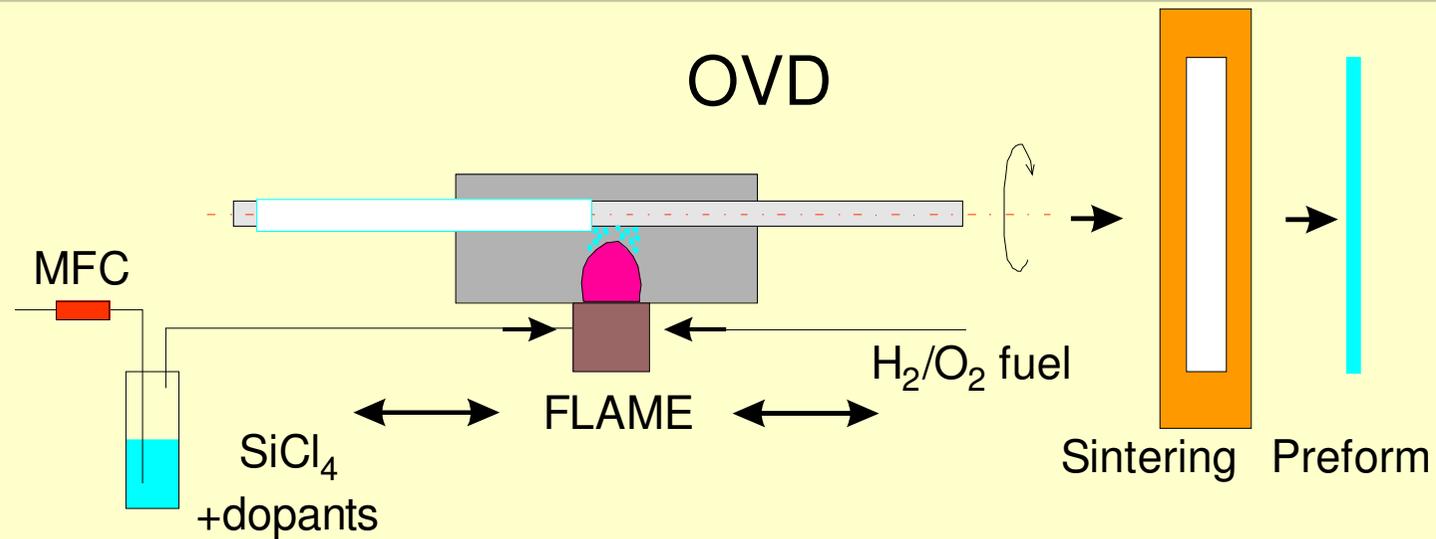
Microphoto of cross section
of produced preform



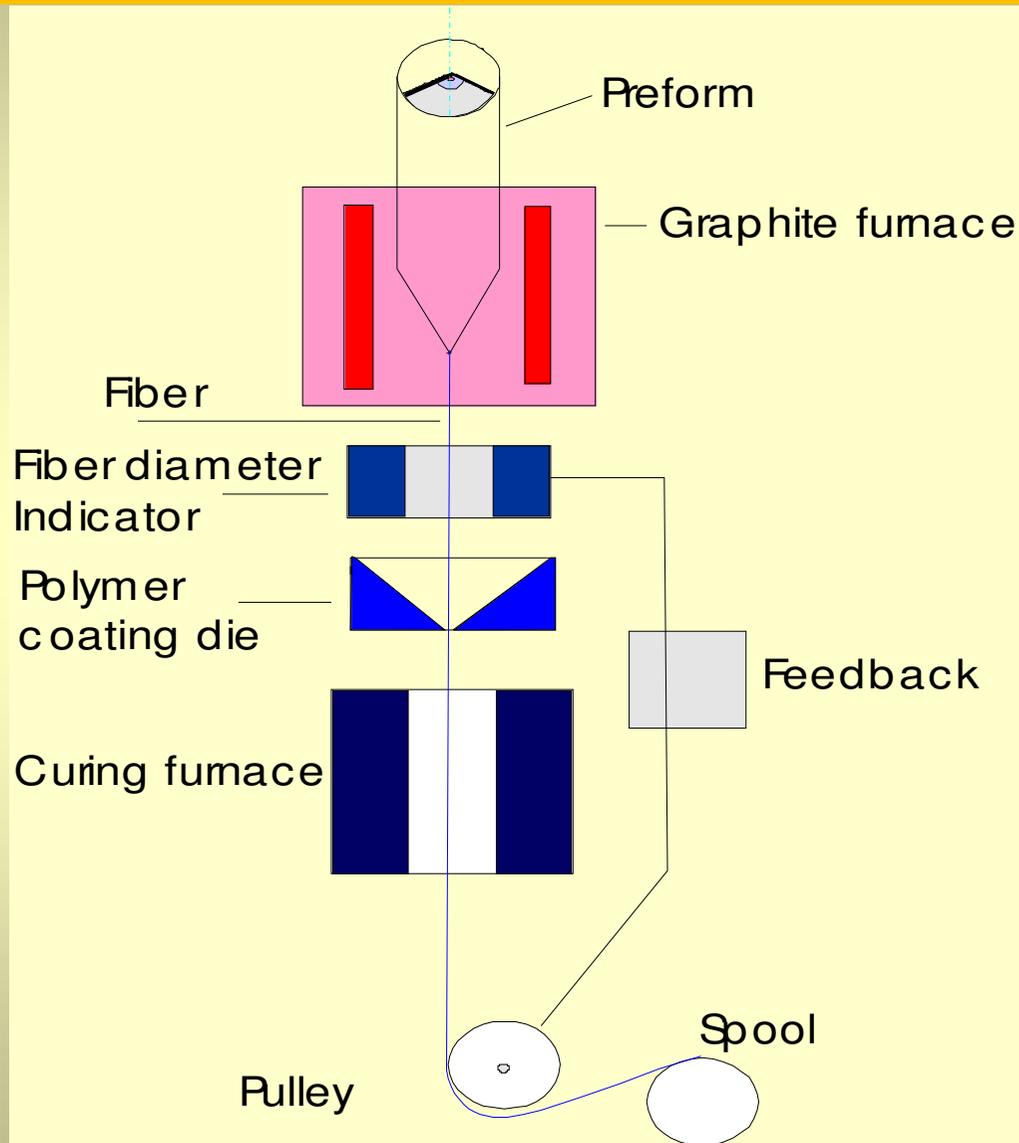
Tomography of the refractive-
index profile of preform

- High purity material due to FO-Optipur purity starting materials.
- High quenching rate ranging from 10^2 to 10^3 °C/s.

Other CVD Technologies

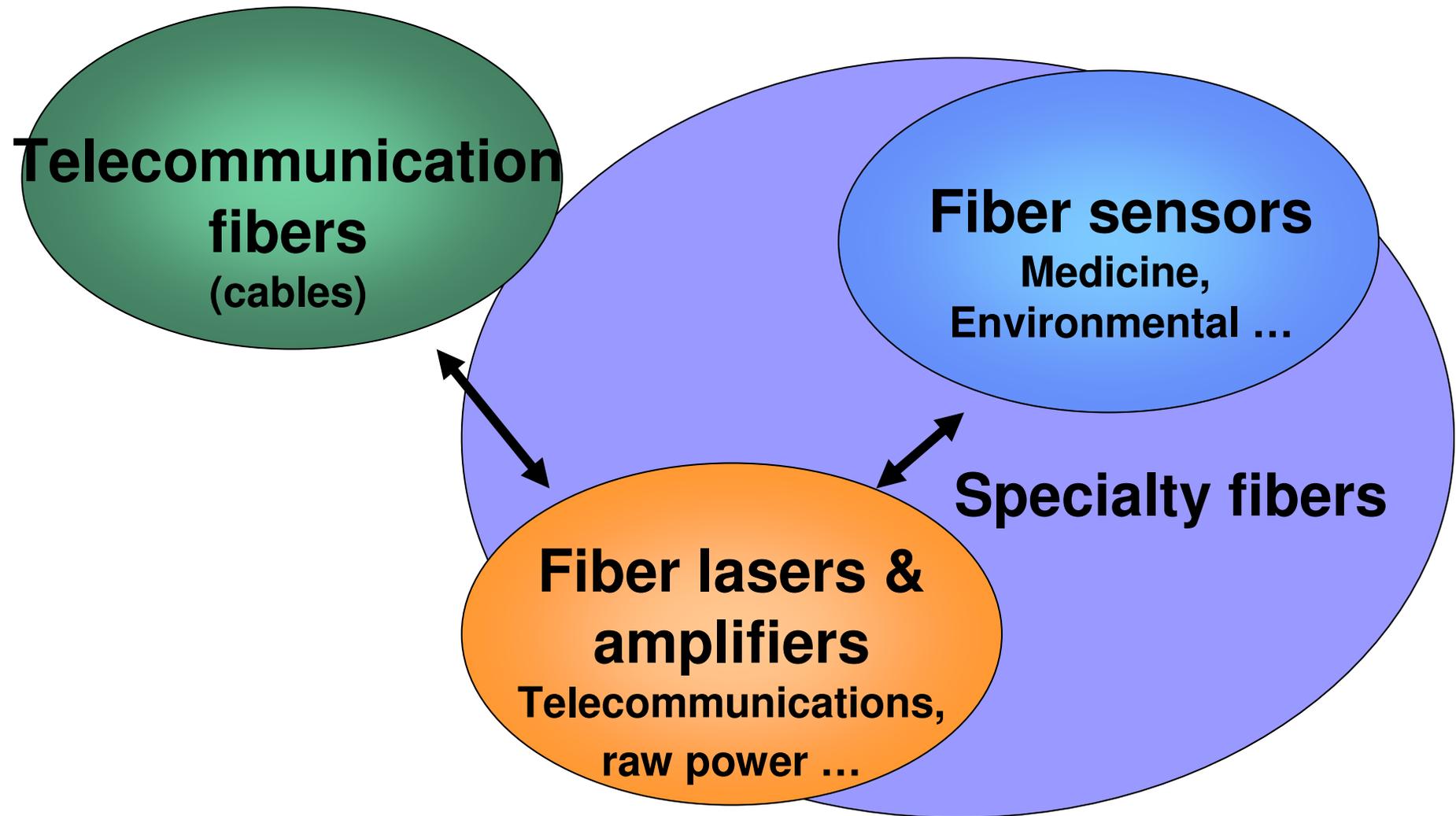


Drawing of Optical Fibers



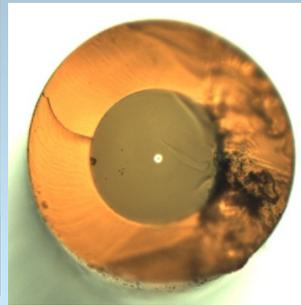
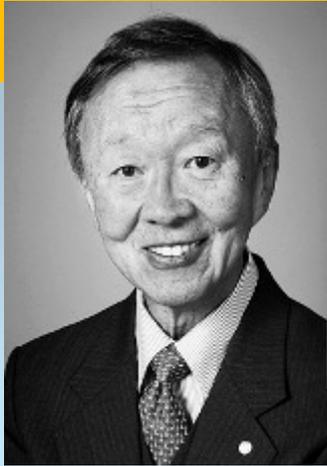
- diameter
80-1000 μm
- temperature
1800-2000 $^{\circ}\text{C}$

Application

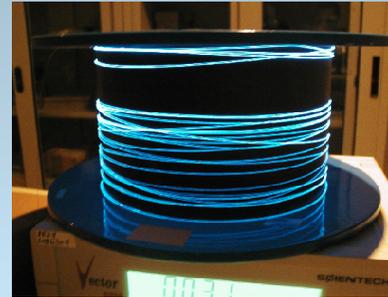


Telecommunications

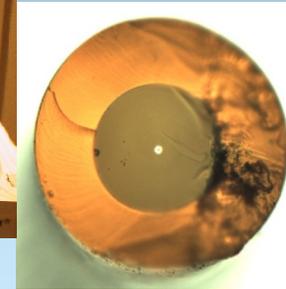
Kao
1966



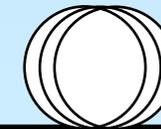
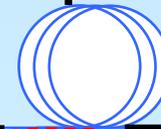
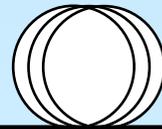
100 km fiber



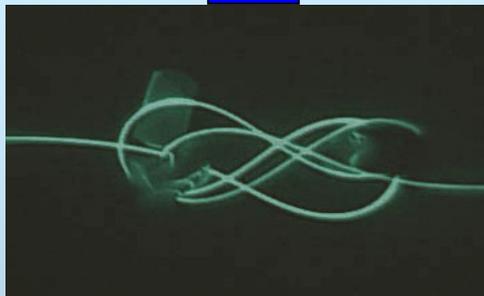
Fiber
amplifier



source



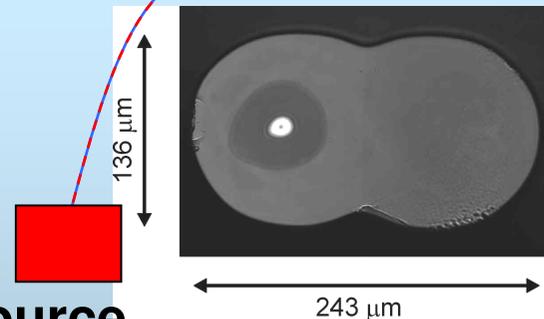
detector



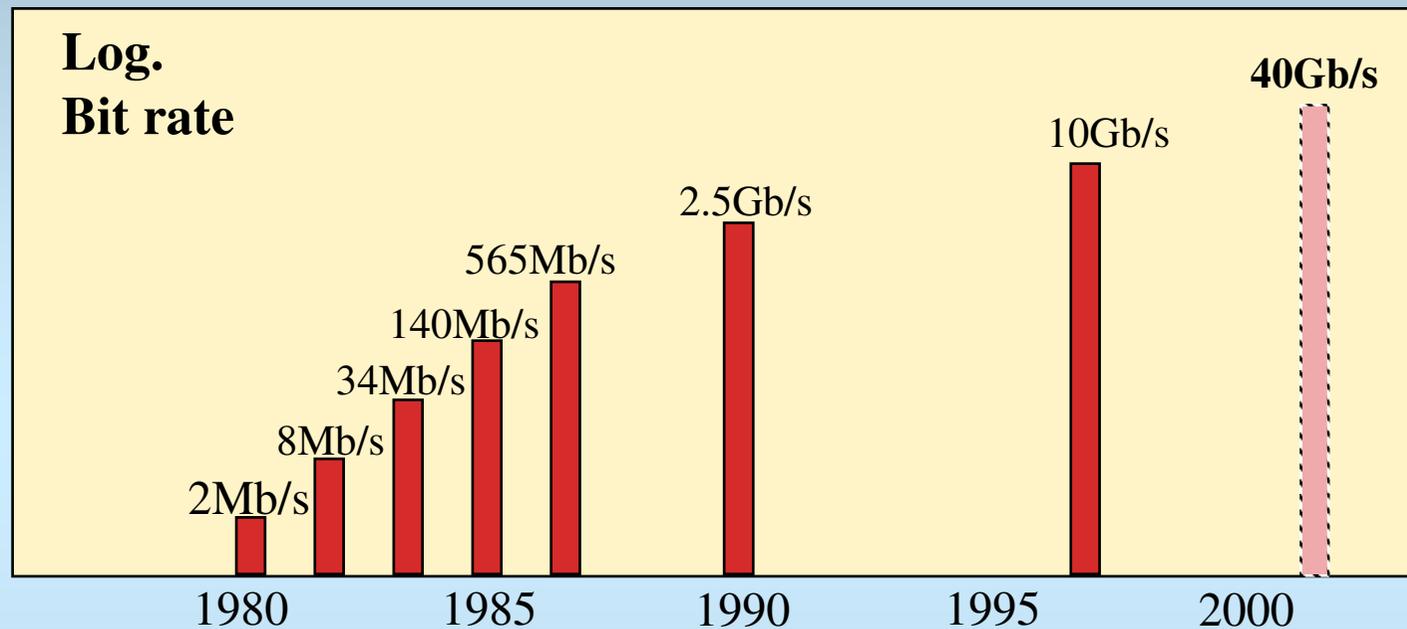
Maiman
1960



source



Communications : increasing requirements on speed and ammount of information



Information Society - IST - Priority of 7 FP

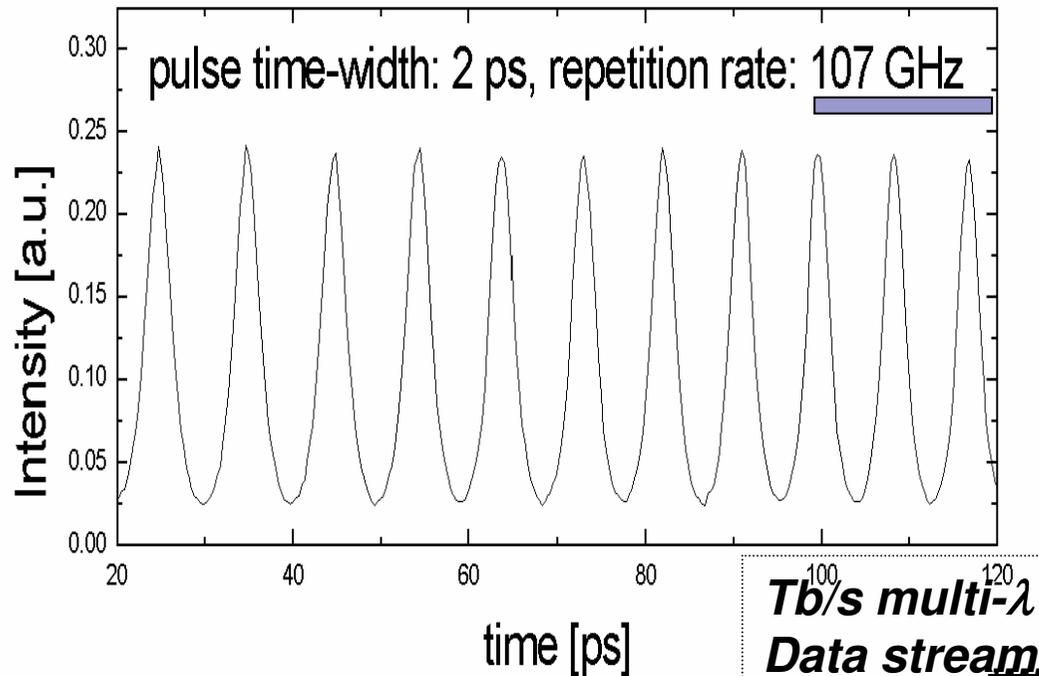
Solution : multiplexing

Time domain (TDM)

Spectral domain (WDM)

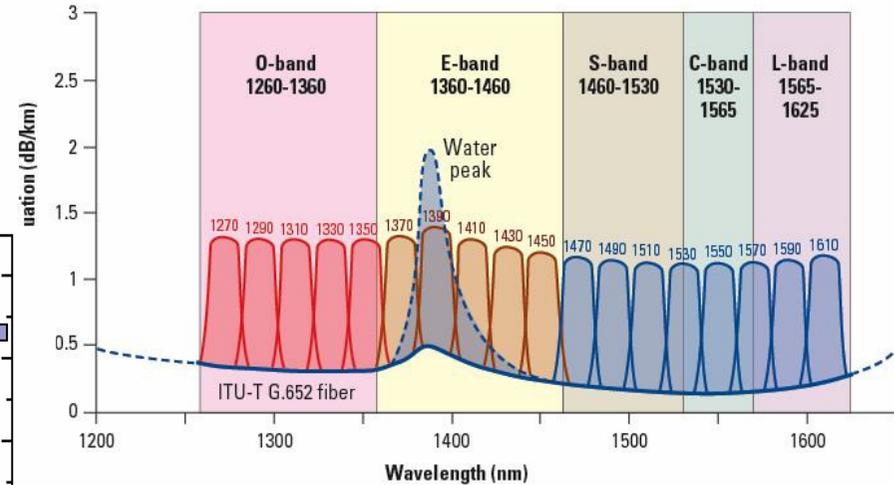
TDM

Time Division Multiplexing (TDM)

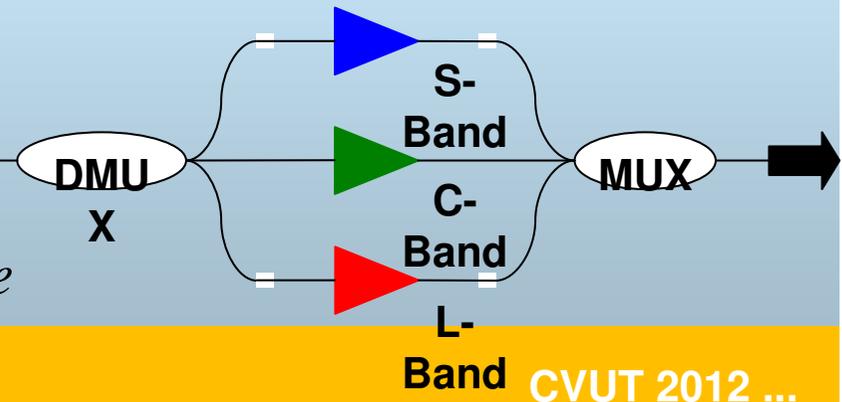


WDM

CWDM wavelength grid as specified by ITU-T G.694.2



Wavelength Division Multiplexing (WDM)

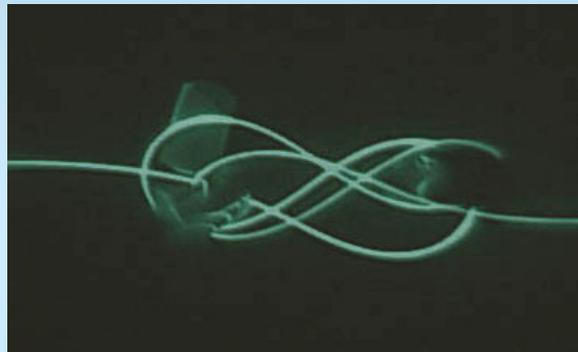


In collaboration with CTU-FJFI, LPMC Nice

SPECIAL OPTICAL FIBERS

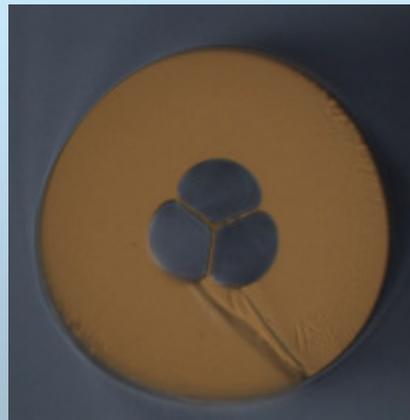
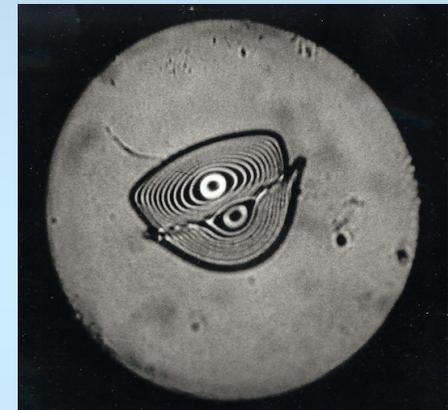
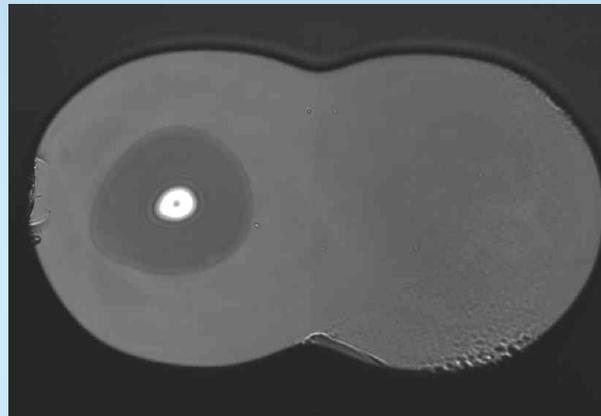
for fiber lasers, amplifiers

Doped fibers



Yb/Er, Tm

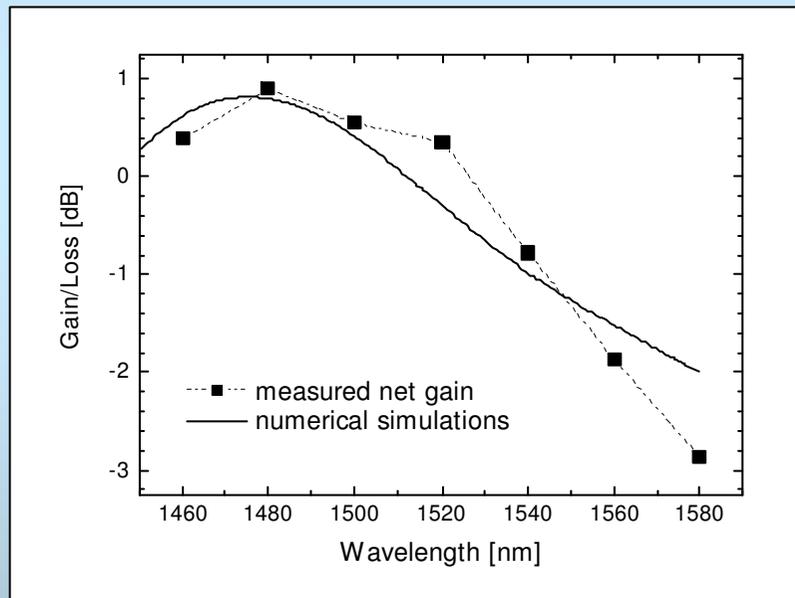
Components



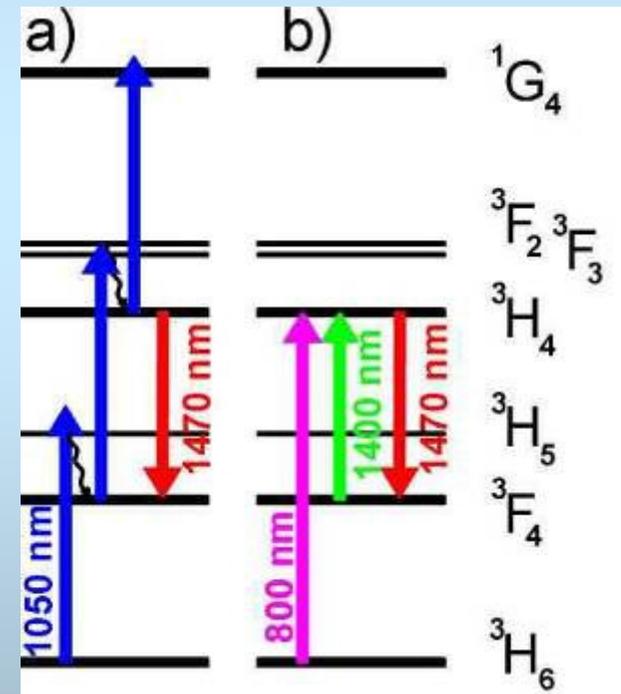
Twin-core (TCF)
Photonic crystal (PCF)
Double-clad (DC)

Tm³⁺ -doped fibers

- Goal : amplification at **S-band** - WDM
- Technol. challenge : special optical fiber fiber efficiently operating at S-band (~1470 nm) and compatible with network. Tm³⁺-Al₂O₃-GeO₂-SiO₂ high NA, narrow core fiber.

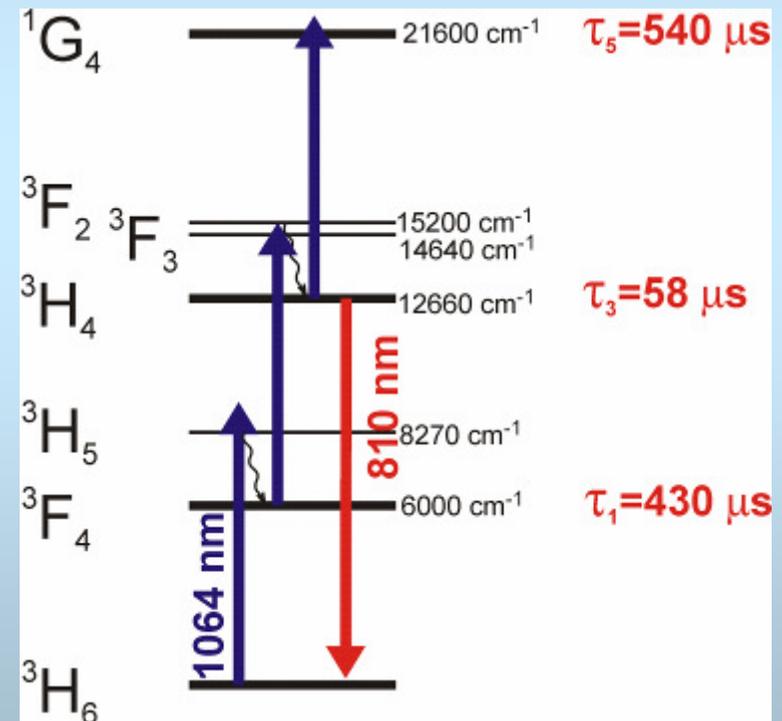
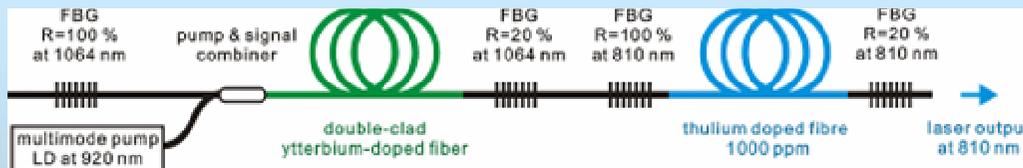


- *P.Peterka - in collaboration with LPMC Nice*



Tm³⁺ -doped fibers

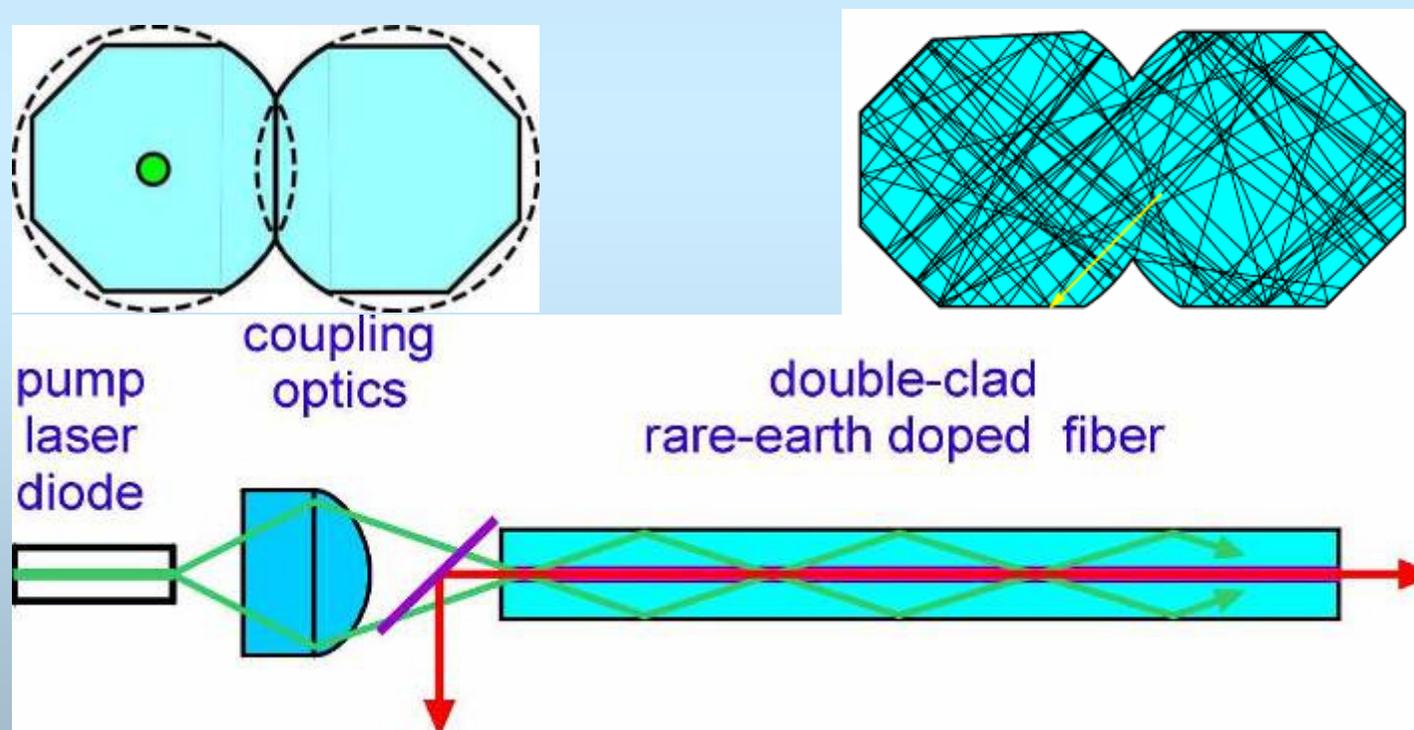
- Goal : a compact upconversion fiber laser operating ~ 810 nm
- Technol. challenge : special optical fiber efficiently operating (~ 810 nm) - Tm³⁺-Al₂O₃-SiO₂ with enhanced 3H₄ lifetime.



Fiber-optic components

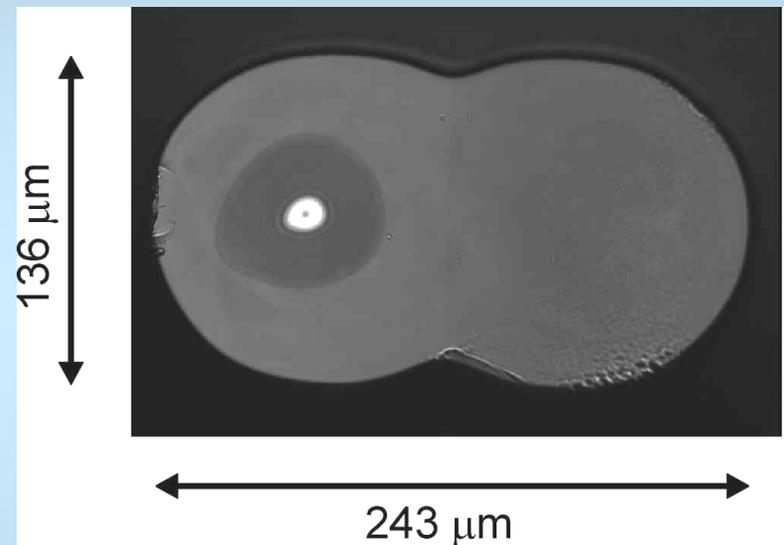
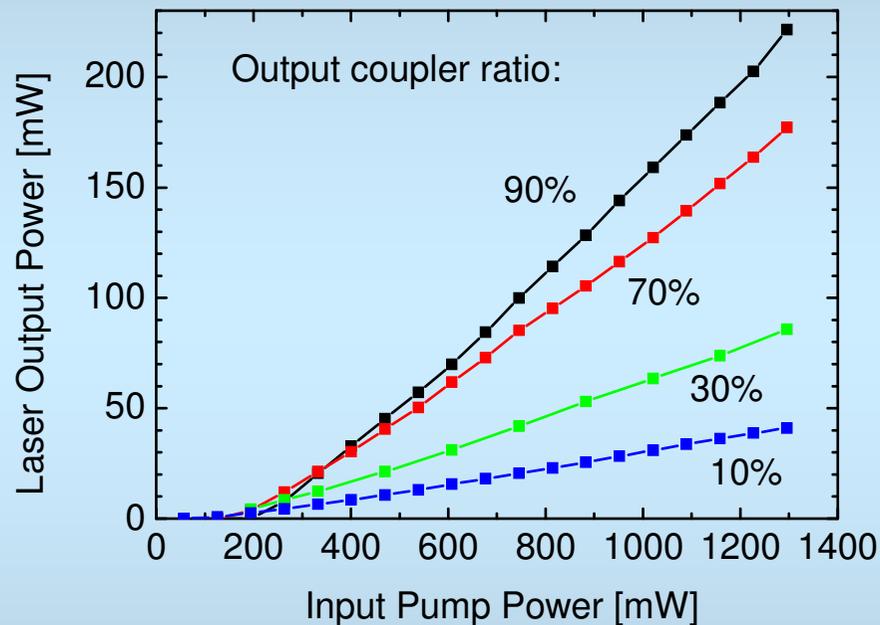
Double-clad (DC) doped optical fiber

- Goal: efficient pumping of fiber lasers (using LD, LED)
- Technol. challenge: special optical fiber of **Double-clad (DC) structure and doped core** of suitable shape for coupling



Fiber-optic components

Double-clad (DC) doped optical fiber

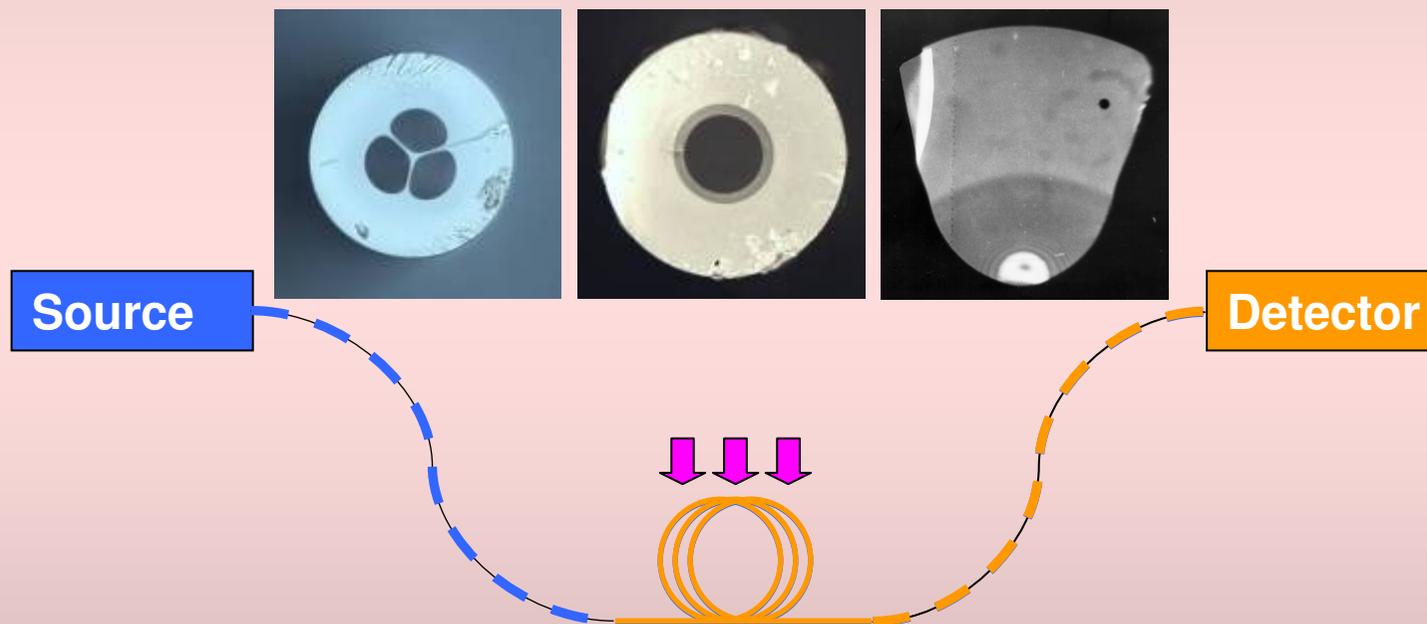


Max. PCE=19%; Yb/Er-doped DC fiber

In collaboration with FJFI CTU

Fiber-optic sensors

Continual reversible monitoring of (bio)chemical species and their concentration



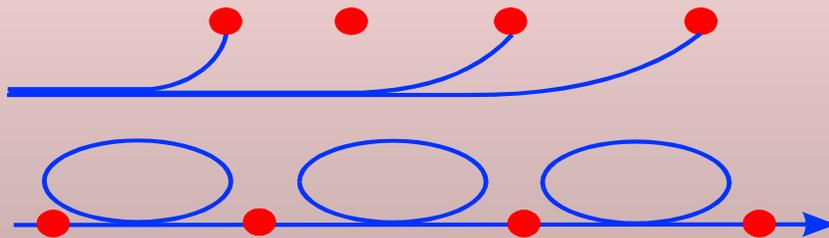
Change of output optical signal due to (bio)chemical changes in fiber vicinity.

Environmental monitoring, medicine, biology, homeland security

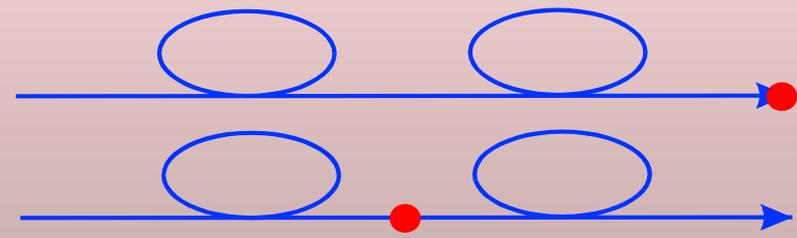
- + Remote sensing
- + Distributed
- + Explosive, high-voltage areas, human body

Solution : fiber-optic sensors

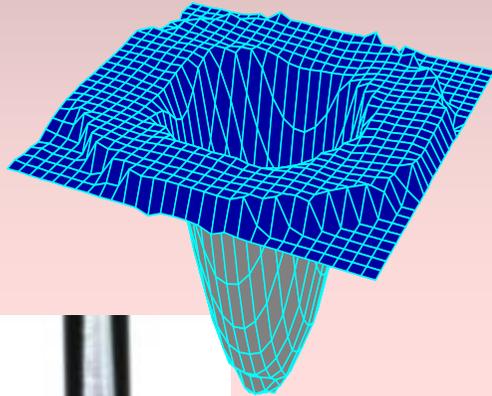
Multipoint (distributed) detection



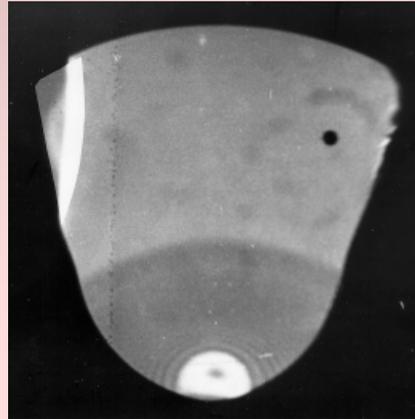
Point detection



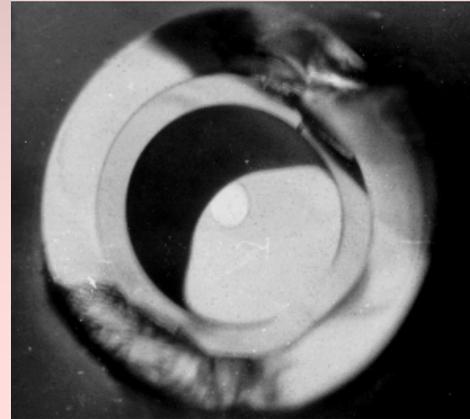
SPECIAL OPTICAL FIBERS for fiber sensors



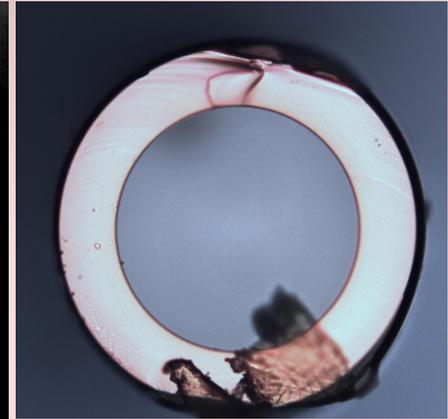
IGI
LPG



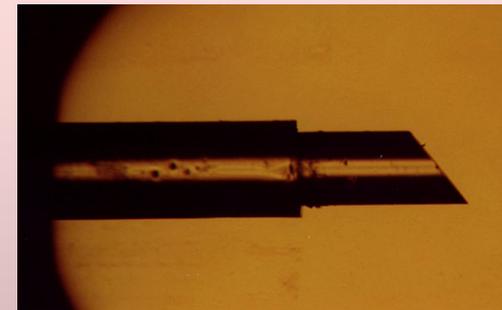
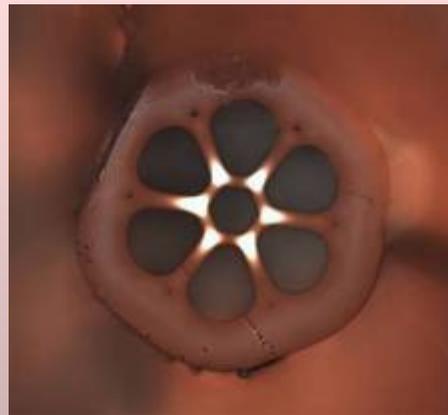
S-fibers



COF-fibers



capillaries



[PCF], tapers

Refractometric sensor of hydrocarbons

Detection of leakage

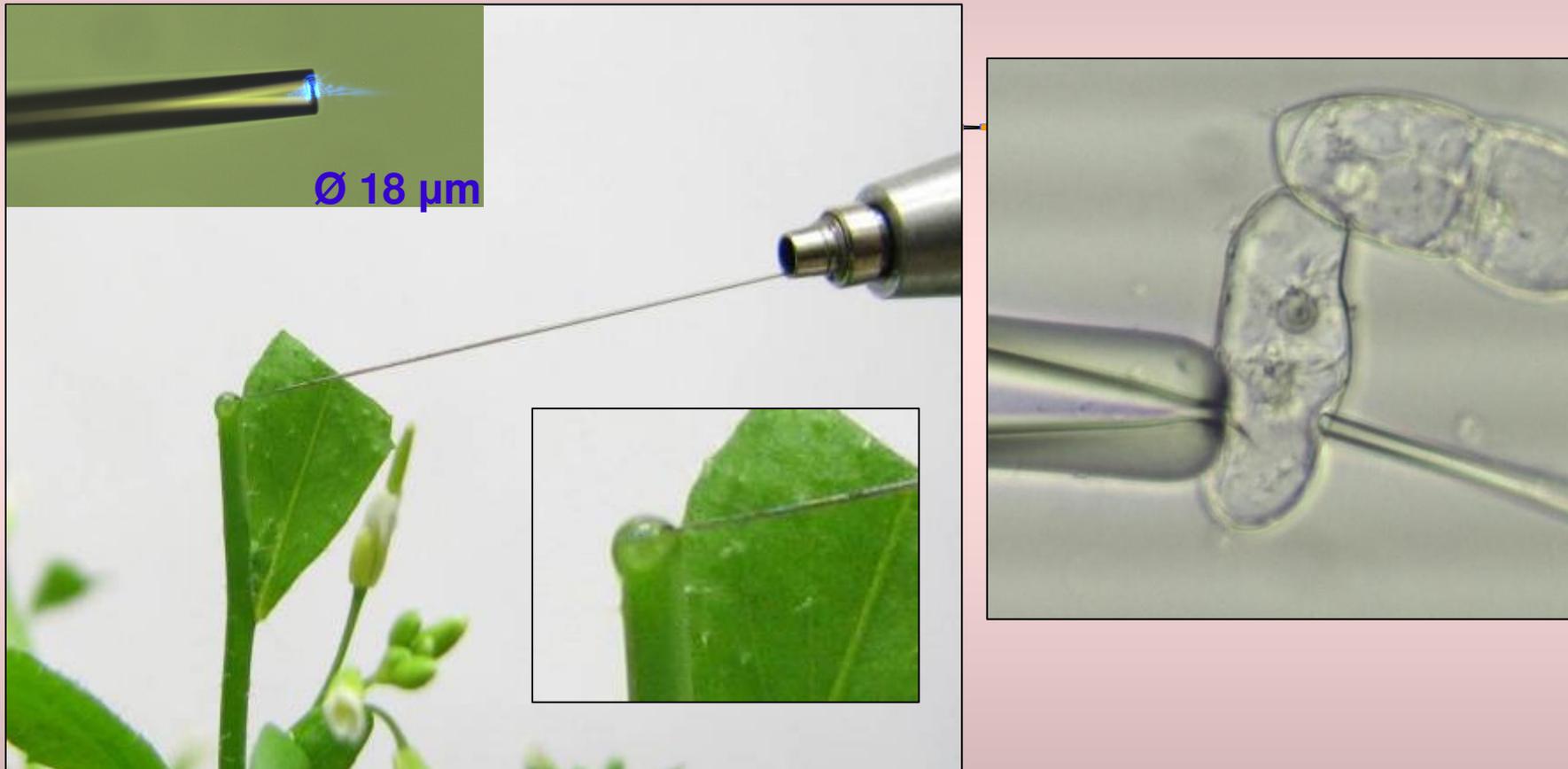


LOD ~ 3-5 mg/l (comparable to EU limits)

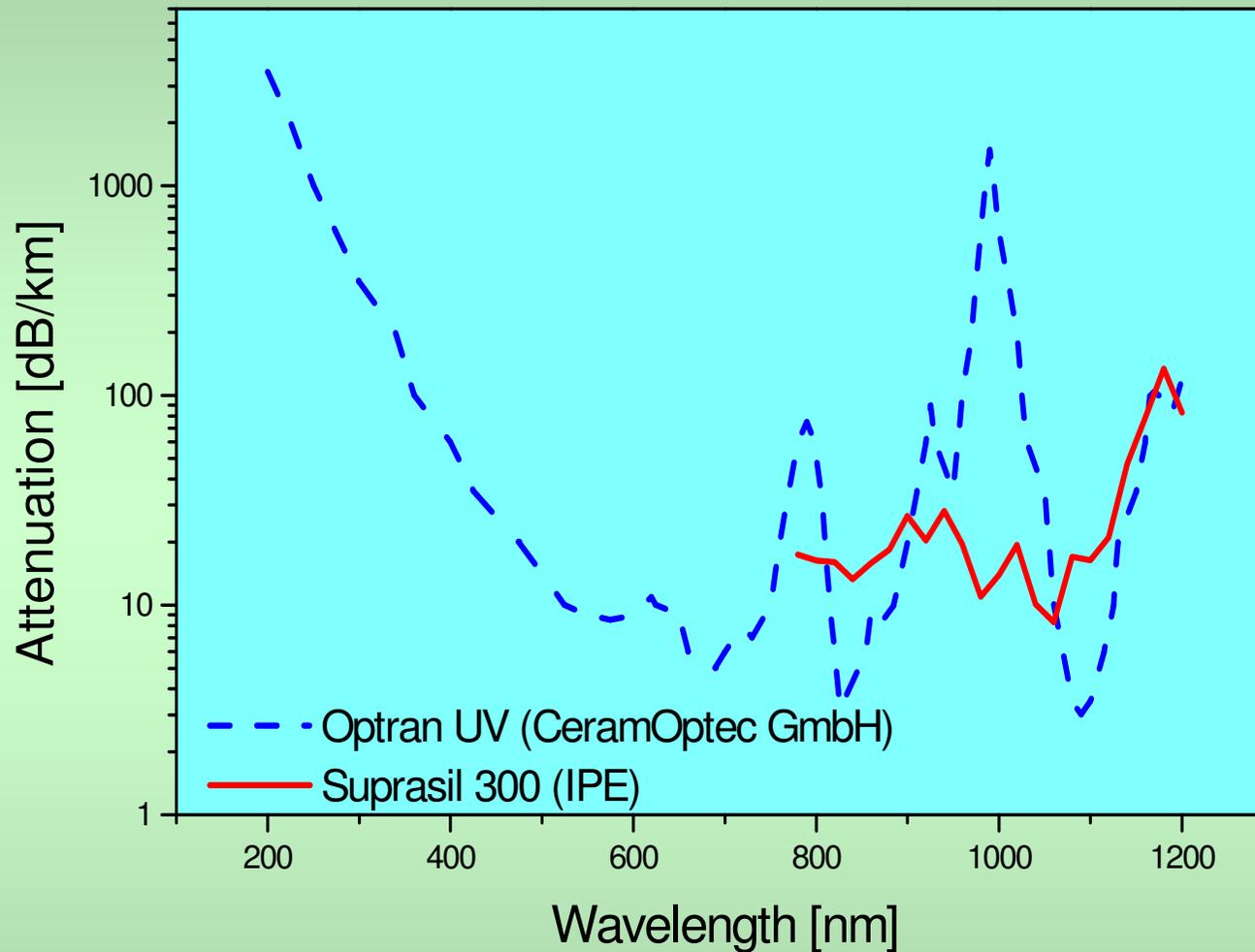
POZVÁNKA : TVT 15.11. 2012 Akademie věd Národní 3

Optical fiber sensors

Detection of pH in small samples (droplets, cells)

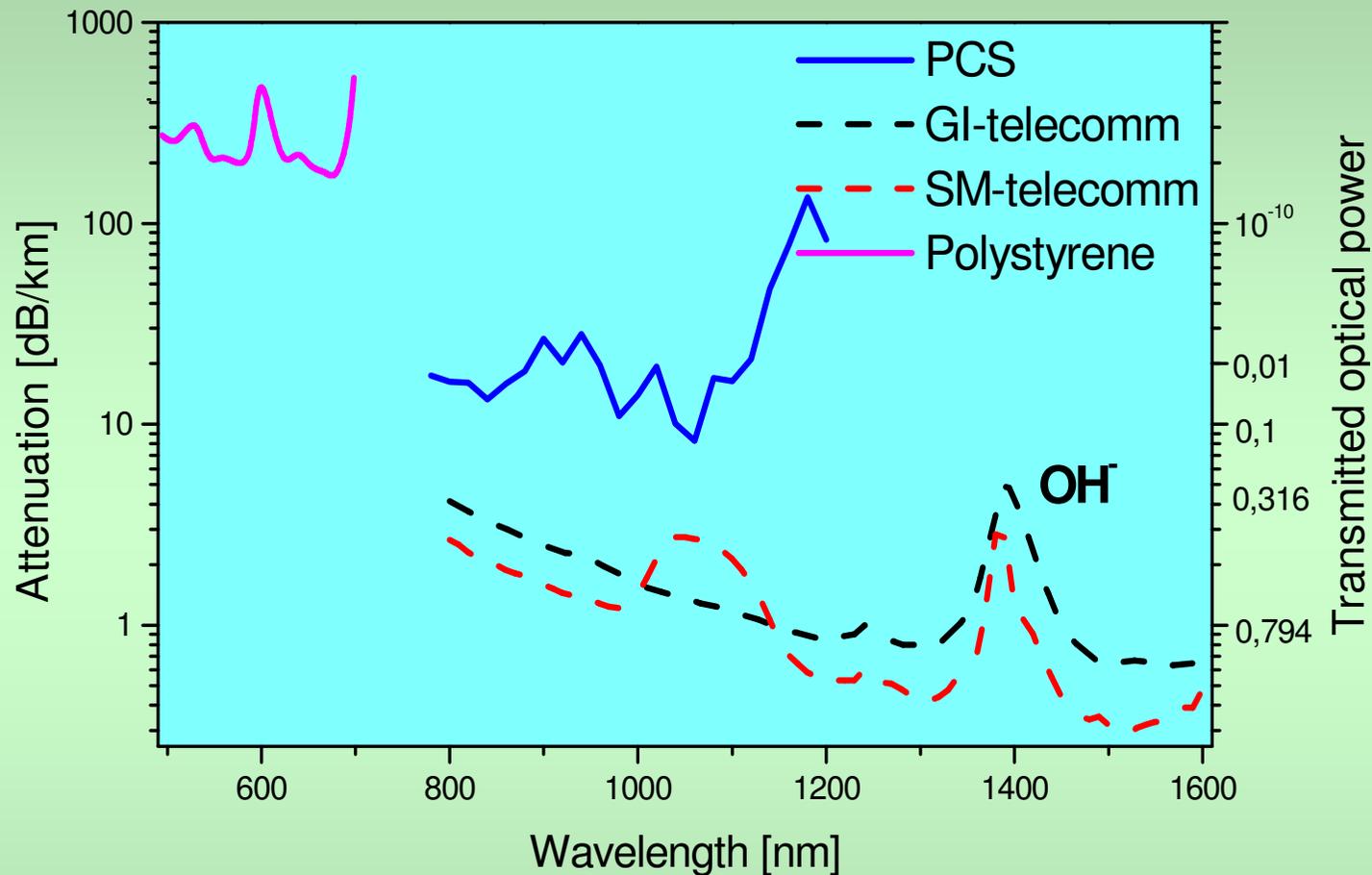


OPTICAL FIBRES – Materials - UV



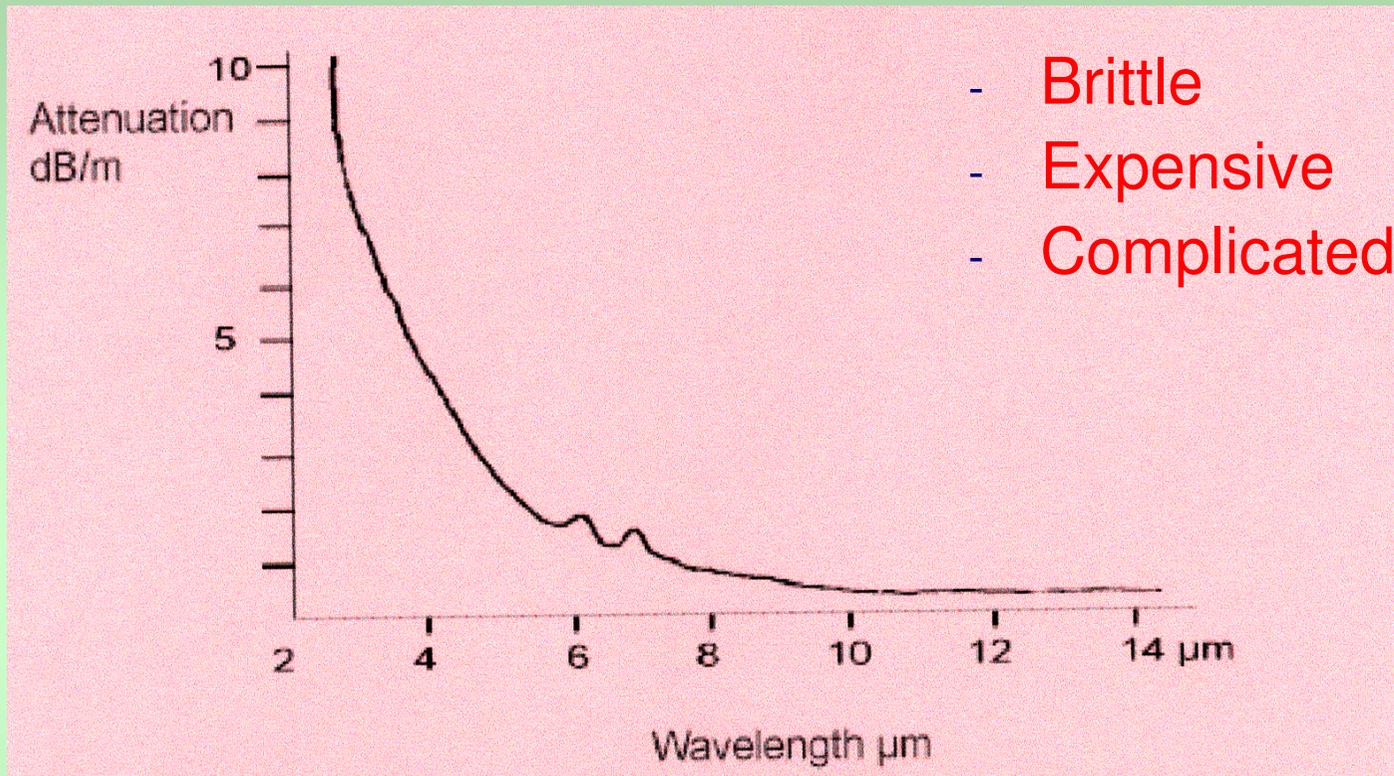
- silica fibres - SUPRASIL $n_{200\text{ nm}} = 1.55$ [[ceramoOptec.de](#), [OceanO](#), [IPE ...](#)]
- planar silica, crystalline CaF_2 (MgF_2) – [[edmundoptics](#), [technicalglass ...](#)]

OPTICAL FIBRES – Materials – VIS/NIR



Silica $n_{633} = 1.457$ & doped silica $n_{633} = 1.45-1.50$ [corning, lucent, ocean_o, IPE]
Glass (silicate - Simax, Vycor, Pyrex) $n_{588} = 1.5-1.95$ [schott, LiFaTec.de, IPE...]
Plastic $n_{588} = 1.5-1.6$ [mitsubishi.com, luceat.it, unlimited-inc.com...]

OPTICAL FIBRES – Materials - IR



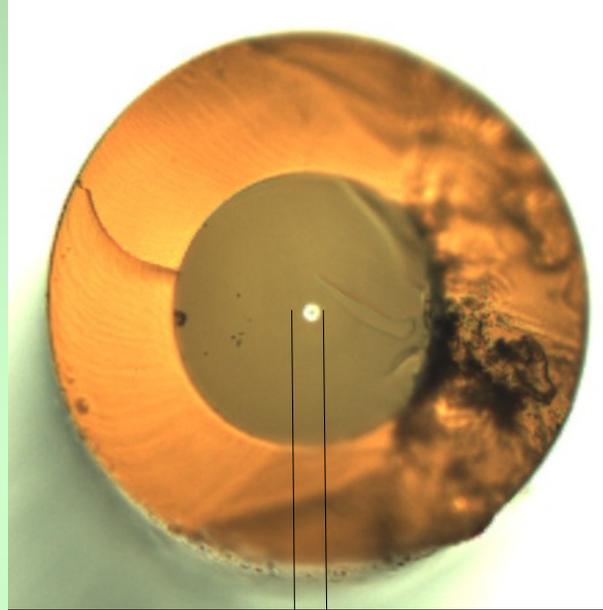
- fluoride glasses [univ-rennes1.fr ...] (up to ~4 μm)
- sapphire [CRYTUR] (up to ~4 μm)
- silver-halides $\text{AgCl}_x\text{Br}_{1-x}$ (up to 15 μm)
- chalco glasses (Se, As_2S_3 , As_2Se_3 ...) [oxford-electronics, orc.soton.ac.uk] (< 20 μm)
- refractive indexes $_{2-20\mu\text{m}} \sim 2 - 2.5 \gg$ silicate glasses [LiFaTec]

OPTICAL FIBRES - Structures

Single-mode

$\varnothing_{\text{core}}$ 2-15 μm

NA 0.1-0.25



Multimode

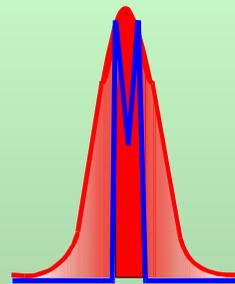
$\varnothing_{\text{core}}$ 50-1000 μm

μm

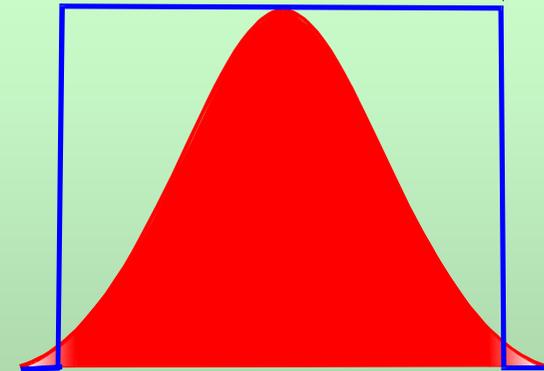
NA 0.2-0.5

+ coupling !

+ connecting !



SM 250/125/7 μm



MM 250/200 μm

SUMMARY

1. **Fiber technology : preparation of structures of high preciseness from materials of ultra-high purity (impurities in ppbs only).**
2. **Fiber preparation in two steps : preform preparation and fiber drawing. (M)CVD technique (preform) makes possible to prepare multilayered tailored structures of suitable level of purity.**
3. **Fibers conventional (passive) and specialty (active).**
4. **Research of optical fibers (CR) :**



References

- **J. M. Senior** : *Optical fiber communications - Principle and practise*, Pearson Education Limited, Harlow, England, 2009.
- **A. Mendez, F.T. Morse** : *Specialty optical fibers handbook*, Elsevier Science & Technol, USA, 2006.
- **J. Schrofel, K. Novotný** : *Optické vlnovody*, SNTL, 1986
- **Saaleh**, *Fotonika* (1 - 4), Matfyzpres

- **S. R. Nagel, J. B. McChesney, K. L. Walker** : An overview of the **MCVD** process and performance, *IEEE J. Quantum Electron.* QE-18 (1982) 459-477

- *Československý časopis pro fyziku* 1/2010, 4-5/2010, 1/2011
- *Jemná mechanika a optika* 55 (2010)
- *Sdělovací technika* 3/2011